# Towards large-scale hexagonal boron nitride 2D layers: a chemical approach



Interfaces

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### UMR CNRS 5615 Laboratoire Multimatériaux Interfaces

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# G

### http://lmi.cnrs.fr from molecule ...

... to material











**DE LYON** 



![](_page_2_Picture_0.jpeg)

![](_page_3_Figure_0.jpeg)

![](_page_3_Figure_1.jpeg)

## **Towards layered hBN**

Several needs of h-BN samples :

![](_page_4_Picture_3.jpeg)

![](_page_4_Picture_4.jpeg)

![](_page_4_Picture_5.jpeg)

Thick layers to be used as substrate for graphene

Encapsulating layers of graphene and other 2D materials

Dielectric layers in heterostructures

Need of both monolayers and thick layers (> 10 – 50 nm)

![](_page_4_Picture_10.jpeg)

## **Our approach**

# **High quality h-BN source**

![](_page_5_Picture_3.jpeg)

![](_page_5_Picture_4.jpeg)

### **Polymer Derived Ceramics (PDCs)**

- Tailored molecular precursor
- Non-oxide system for high purity
- Liquid precursors easy to handle
- Possibility for various shaping methods for specific ceramic shape

S. Yuan, et al. Crystals. 2016, 6, 55
S. Yuan, et al. Nanoscale. 2014, 6, 7838-7841
P. Colombo. J. Am. Ceram. Soc. 2010, 93, 1805-1873

### Spark Plasma Sintering (SPS)

- Rapid and efficient processing method for densification on both lab scale and industrial level
- Softer condition compared with HPHT method (2100°C, 5.5GPa, 80h)

S. Yuan, et al. Sci. Rep. **2016**, 6, 20388 E. Bernardo, et al. Ceram. Int. **2014**, 40, 14493-14494 K. Watanabe, et al. Nat. Mater. **2004**, 3, 404–409

![](_page_5_Picture_15.jpeg)

Laboratoire des Multimatériaux et Interfaces **Polymer Derived Ceramics (PDCs) route** Interfaces **Bonabist**s  $(NH_4)_2SO_4 + NaBH_4$  in tetraglyme pressure vessel 50°C / 7 days **Hone aiside inen** cristallisation promoter Li<sub>3</sub>N Ceramisation additivation 1000-1800°C / N<sub>2</sub> **Buaping**N **BHN6** sis UNIVERSITÉ DE LYON CINIS

![](_page_7_Figure_0.jpeg)

![](_page_8_Figure_0.jpeg)

![](_page_9_Figure_0.jpeg)

![](_page_10_Picture_1.jpeg)

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### Influence of the crystallization promoter

No	Pre-ceramic Composition	Li <sub>3</sub> N wt. %	Temperature °C	Pressure MPa	Dwelling time hour
1	PBN	0	1800	90	1
2	PBN+Li <sub>3</sub> N	5	1800	90	1
3	PBN+Li <sub>3</sub> N	10	1800	90	1

![](_page_10_Picture_4.jpeg)

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### Influence of the crystallization promoter

![](_page_11_Figure_4.jpeg)

Ceramic yield decreases when increasing Li<sub>3</sub>N amount

![](_page_12_Picture_1.jpeg)

CINS

## **Influence of the sintering T**

No	Pre-ceramic Composition	Li <sub>3</sub> N wt. %	Temperature °C	Pressure MPa	Dwelling time hour
1	PBN+Li <sub>3</sub> N	5	1200	90	1
2	PBN+Li <sub>3</sub> N	5	1500	90	1
3	PBN+Li <sub>3</sub> N	5	1800	90	1
4	PBN+Li <sub>3</sub> N	5	1950	90	1

![](_page_12_Picture_5.jpeg)

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### Influence of the sintering T

![](_page_13_Figure_3.jpeg)

Flakesenses Shorthsint paretecheren aximum area of 276 μm<sup>2</sup> at 1800°C and Δ at 1950°C

> Where raip de eid goff defined a random insate a ke dfa atter ftakers anyst growing tim raite relate

best compromise between 1500 and 1800°C

![](_page_13_Picture_8.jpeg)

### **Influence of the sintering T**

1200°C 1500°C Intensity (a.u.) Intensity (a.u.) Center: 1366.2 cm<sup>-1</sup> Center: 1366.1 cm<sup>-1</sup> FWHM: 8.61 cm FWHM: 8.07 cm<sup>-1</sup> 1200 1250 1300 1350 1400 1450 1500 1550 1200 1250 1300 1350 1400 1450 1500 1550 Frequency Shift (cm<sup>-1</sup>) Frequency Shift (cm<sup>-1</sup>) 1800°C 1950°C Intensity (a.u.) Intensity (a.u.) Center: 1366.0 cm Center: 1365.8 cm FWHM: 7.81 cm FWHM: 8.31 cm<sup>-1</sup> 1200 1250 1300 1350 1400 1450 1500 1550 1200 1250 1300 1350 1400 1450 1500 1550 Frequency Shift (cm<sup>-1</sup>) Frequency Shift (cm<sup>-1</sup>)

Raman

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Very good Raman signature with a FWHM  $\approx 8 \text{ cm}^{-1}$ 

![](_page_14_Picture_4.jpeg)

### Good crystalline structure of h-BN

![](_page_14_Picture_6.jpeg)

XRD

### Influence of the crystallization promoter and sintering T

Collab. GEMAC & ONERA (A. Plaud, L. Schue, J. Barjon, A. Loiseau)

Investigation of optical and excitonic properties

A tool of interest

identification of different classes of defects and their impact on optical properties

![](_page_15_Figure_5.jpeg)

### Influence of the crystallization promoter and sintering T

Indication of the overall material quality, accounting for both purity and crystallinity

![](_page_16_Figure_3.jpeg)

- Observation of intrinsic exciton emission (S-lines)
- Absence of defect-related emissions (D-lines)
- Presence of impurities when increasing the sintering temperature : contamination ?

Collab. GEMAC & ONERA (L. Schue, J. Barjon, A. Loiseau)

![](_page_16_Picture_8.jpeg)

![](_page_17_Picture_0.jpeg)

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### From h-BN pellets ... towards flakes

![](_page_17_Picture_3.jpeg)

well-crystallized h-BN bulk sample (pellet) b) <u>10 μm</u>

flake (single crystal)

![](_page_17_Picture_7.jpeg)

![](_page_18_Picture_0.jpeg)

### **Characterization of the flakes**

![](_page_19_Figure_2.jpeg)

![](_page_20_Figure_0.jpeg)

![](_page_21_Picture_0.jpeg)

## **Characterization of the BNNSs**

![](_page_21_Picture_3.jpeg)

Laboratoire des Multimatériaux et Interfaces ഗ്ര **Characterization of the BNNSs** aboratoire Multimatériaux Interfaces **EELS** 300 k a) Nitrogen Boron 200 k 80 k K-edge K-edge 00 k Counts 40 k onuts 0 100 k 200 k Counts 20 k 50 k 400 405 410 Energy Loss (eV) 190 200 210 220 180 230 415 Energy Loss (eV) 100 k N 100 200 300 400 500 Energy Loss (eV) Carbon Lithium Oxygen П K-edge K-edge K-edge 40 80 k 1.5 M Counts Counts 1 00 Counts 1 M 40 H 10 k 0.5 M 20 k 0 k 50 60 Energy Loss (eV) 530 540 Energy Loss (eV) 40 260 280 Energy Loss (eV) 300 520 UNIVERSITÉ DE LYON CINIS Graphene 2018 – 26-29 June 2018 - Dresden, Germany

![](_page_23_Picture_0.jpeg)

# **Conclusions & Outline**

- BNNS as ideal candidate for graphene substrate / encapsulating layer / 2D layers staking
- Increase of the crystallinity by adding Li<sub>3</sub>N
  - Higher crystallinity at lower temperature
- Interest in combining the PDCs route & the SPS to get h-BN large single crystals
- After exfoliation, large (tens of μm) and defect-free BNNSs obtained

![](_page_23_Picture_8.jpeg)

![](_page_23_Picture_9.jpeg)

S. Yuan et al. Crystals, 6, 55 (2016)

![](_page_23_Picture_12.jpeg)

![](_page_23_Picture_13.jpeg)

![](_page_23_Picture_14.jpeg)

![](_page_24_Picture_1.jpeg)

![](_page_24_Figure_2.jpeg)

- Bérangère Toury
- Sheng Yuan

![](_page_24_Picture_5.jpeg)

- Philippe Steyer
- Vincent Garnier

![](_page_24_Picture_8.jpeg)

ONERA

SAINT-QUENTIN-EN-YVELINES

GRAPHENE

FLAGSHIP

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Thank you for your attention !

- Annick Loiseau
- Alexandre Plaud
- Julien Barjon

ANR

Cors

![](_page_24_Picture_13.jpeg)

![](_page_24_Picture_14.jpeg)